PMC-ND

U.S. DEPARTMENT OF ENERGY (1.08.09.13)OFFICE OF ENERGY EFFICIENCY AND RENEWABLE ENERGY NEPA DETERMINATION



STATE: CA **RECIPIENT:** Halo Industries, Inc.

PROJECT Advanced Silicon Carbide Wafer Manufacturing for Low Cost, High Efficiency Power Electronics in

TITLE: Solar Applications

Funding Opportunity Announcement Number Procurement Instrument Number NEPA Control Number CID Number DE-FOA-0002064 DE-EE0009016 GFO-0009016-001

Based on my review of the information concerning the proposed action, as NEPA Compliance Officer (authorized under DOE Policy 451.1), I have made the following determination:

CX, EA, EIS APPENDIX AND NUMBER:

Description:

A9 Information gathering,

Information gathering (including, but not limited to, literature surveys, inventories, site visits, and audits), data analysis (including, but not limited to, computer modeling), document preparation (including, but not limited to, conceptual design, feasibility studies, and analytical energy supply and demand studies), and information analysis, and dissemination (including, but not limited to, document publication and distribution, and classroom training and dissemination informational programs), but not including site characterization or environmental monitoring. (See also B3.1 of appendix B to this subpart.)

B3.6 Smallscale **laboratory** operations, and pilot projects

Siting, construction, modification, operation, and decommissioning of facilities for smallscale research and development projects; conventional laboratory operations (such as preparation of chemical standards and research and sample analysis); and small-scale pilot projects (generally less than 2 years) frequently conducted to verify a development, concept before demonstration actions, provided that construction or modification would be within or contiguous to a previously disturbed or developed area (where active utilities and currently used roads are readily accessible). Not included in this category are demonstration actions, meaning actions that are undertaken at a scale to show whether a technology would be viable on a larger scale and suitable for commercial deployment.

Rationale for determination:

The U.S. Department of Energy (DOE) is proposing to provide federal funding to Halo Industries to develop a novel laser-based manufacturing process for the fabrication of silicon carbide wafers from silicon carbide ingots. The process would be developed to lower costs and increase throughput as compared to current technologies (e.g. wire saw manufacturing). An existing, early-stage prototype device would be developed further and used to demonstrate the viability of the technology and to assess the quality of the resulting wafers.

The project would be completed over two Budget Periods (BPs), with a Go/No-Go Decision Point in between each BP. Proposed project activities would include data analysis, material characterization, process optimization, fabrication of sample silicon carbide wafers, stakeholder engagement (e.g. market analysis and product demonstrations), and cost modeling. Throughout the project, Halo Industries would work to optimize the laser-based wafer slicing process, both in terms of material loss and production time. Incremental improvements would be made both to the technology itself and to the associated processes via iterative experimentation.

All project activities, including wafer fabrication, would be performed by Halo Industries at its existing, purpose-built laboratory facility in Palo Alto, CA. Wafer fabrication would be performed using existing equipment designed for the task. Ingots used for the fabrication would be procured from a commercial silicon carbide wafer manufacturer. The quantities of materials used and produced during sample fabrication would not exceed the scale of past or ongoing research and development (R&D) conducted by Halo Industries; the proposed project does not involve commercialscale production. No physical modifications to existing facilities, construction of new facilities, ground disturbing activities, or changes to the use, mission, or operation of existing facilities would be required. No additional permits, licenses, or authorizations would be required.

Project work would involve the use and handling of industrial solvents (e.g. acetone, methanol, and isopropyl alcohol) and semiconductor materials (e.g. silicon carbide). All such handling would occur in controlled laboratory environments. Risks associated with the performance of project activities would be mitigated through adherence to established corporate health and safety policies and procedures. Protocols would include employee training, the use of proper protective equipment, engineering controls, monitoring, and internal assessments. Halo Industries would observe all applicable Federal, state, and local health, safety, and environmental regulations.

NEPA PROVISION

DOE has made a final NEPA determination.

Notes:

Solar Energy Technologies Office This NEPA determination does not require a tailored NEPA Provision. NEPA review completed by Jonathan Hartman, 12/18/2019

FOR CATEGORICAL EXCLUSION DETERMINATIONS

The proposed action (or the part of the proposal defined in the Rationale above) fits within a class of actions that is listed in Appendix A or B to 10 CFR Part 1021, Subpart D. To fit within the classes of actions listed in 10 CFR Part 1021, Subpart D, Appendix B, a proposal must be one that would not: (1) threaten a violation of applicable statutory, regulatory, or permit requirements for environment, safety, and health, or similar requirements of DOE or Executive Orders; (2) require siting and construction or major expansion of waste storage, disposal, recovery, or treatment facilities (including incinerators), but the proposal may include categorically excluded waste storage, disposal, recovery, or treatment actions or facilities; (3) disturb hazardous substances, pollutants, contaminants, or CERCLA-excluded petroleum and natural gas products that preexist in the environment such that there would be uncontrolled or unpermitted releases; (4) have the potential to cause significant impacts on environmentally sensitive resources, including, but not limited to, those listed in paragraph B(4) of 10 CFR Part 1021, Subpart D, Appendix B; (5) involve genetically engineered organisms, synthetic biology, governmentally designated noxious weeds, or invasive species, unless the proposed activity would be contained or confined in a manner designed and operated to prevent unauthorized release into the environment and conducted in accordance with applicable requirements, such as those listed in paragraph B(5) of 10 CFR Part 1021, Subpart D, Appendix B.

There are no extraordinary circumstances related to the proposed action that may affect the significance of the environmental effects of the proposal.

The proposed action has not been segmented to meet the definition of a categorical exclusion. This proposal is not connected to other actions with potentially significant impacts (40 CFR 1508.25(a)(1)), is not related to other actions with individually insignificant but cumulatively significant impacts (40 CFR 1508.27(b)(7)), and is not precluded by 40 CFR 1506.1 or 10 CFR 1021.211 concerning limitations on actions during preparation of an environmental impact statement.

The proposed action is categorically excluded from further NEPA review.

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